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PATENT
0941-0809P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: LAI, Sheng-Chih et al. Conf.: 8162
Appl. No.: 10/642,244 Group: 2823
Filed: August 18, 2003 Examiner: W. D. Coleman
For: MASK READ ONLY MEMORY CONTAINING DIODES
AND METHOD OF MANUFACTURING THE SAME

LARGE ENTITY TRANSMITTAL FORM

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

October 29, 2004

Sir:

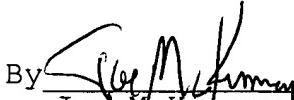
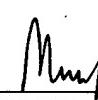
Transmitted herewith is a Reply to Restriction/Election Requirement in the above-identified application.

- The enclosed document is being transmitted via the Certificate of Mailing provisions of 37 C.F.R. § 1.8.
- Petition for _____ month(s) extension of time pursuant to 37 C.F.R. §§ 1.17 and 1.136(a). \$0.00 for the extension of time.
- No fee is required.
- A check in the amount of \$0.00 is enclosed.
- Please charge Deposit Account No. 02-2448 in the amount of \$0.00. A triplicate copy of this sheet is attached.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. §§1.16 or 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

By  
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KM/asc
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Attachment(s)



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REPLY TO RESTRICTION REQUIREMENT

Assistant Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

October 29, 2004

Sir:

Responsive to the Office Action dated September 29, 2004, the following election and remarks are respectfully submitted in connection with the above-identified application.

REMARKS

Claims 1-19 are now pending in the present application.

The Examiner has given the following Restriction Requirement:

Group I, claims 1-11, drawn to a semiconductor device; and

Group II, claims 12-19, drawn to a method of manufacturing a semiconductor device.

In response to this requirement, Applicants hereby elect Group I, claims 1-11 drawn to a semiconductor device. This election is with traverse.